

CASE NO.

761 P7

SERIAL NO

08/825,360

INFORMATION DISCLOSURE STATEMENT

(Use several sheets if necessary)

APPLICANT

Liao et al.

FILING DATE

March 28, 1997

GROUP

2814

SEP 06 2000

U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

OTHER (*Including Author, Title, Date, Pertinent Pages, Etc.*)

EXAMINER

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9/22/00

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Form PTO-1449	U. S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	CASE NO. 761 P3	SERIAL NO. 08/677,185
INFORMATION DISCLOSURE STATEMENT <i>(Use several sheets if necessary)</i>		APPLICANT Danek et al. /Iau et al.	08/825360
		FILING DATE 07/09/96 3/28/97	GROUP 1763 2814

U.S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES	NO
Jy		0 738 002 A2	10/16/96	Europe	H01L	21/283		
Jy		0 720 214 A2	07/03/96	Europe	H01L	21/321		
P		0 545 602 A1	06/09/93	Europe	H01L	21/285		
							C 201	HAN RE

OTHER (*Including Author, Title, Date, Pertinent Pages, Etc.*)

TU		Park et al. "A Novel A1-Reflow Process Using Surface Modification by the ECR Plasma Treatment and its Application to the 256Mbit DRAM" Semiconductor R&D Center, Samsung Electronics Co. Ltd. pp. 109-112, Dec. 11, 1994

EXAMINER

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